

Title (en)
POLISHING COMPOSITION

Title (de)
POLITUR

Title (fr)
COMPOSITION DE POLISSAGE

Publication
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Application
EP 02797709 A 20020903

Priority

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- US 31796201 P 20010910

Abstract (en)
[origin: WO03020839A1] A polishing composition of abrasive grains, a phosphorus-containing inorganic acid or salt thereof and another inorganic acid or salt thereof contained in an aqueous medium is used for the polishing of magnetic disk substrates or the like.

IPC 1-7
C09G 1/02

IPC 8 full level
C09G 1/02 (2006.01)

CPC (source: EP US)
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